

# Future Nanocharacterization with Electrons: sub-Ångstrom, sub-eV, and Single Atom

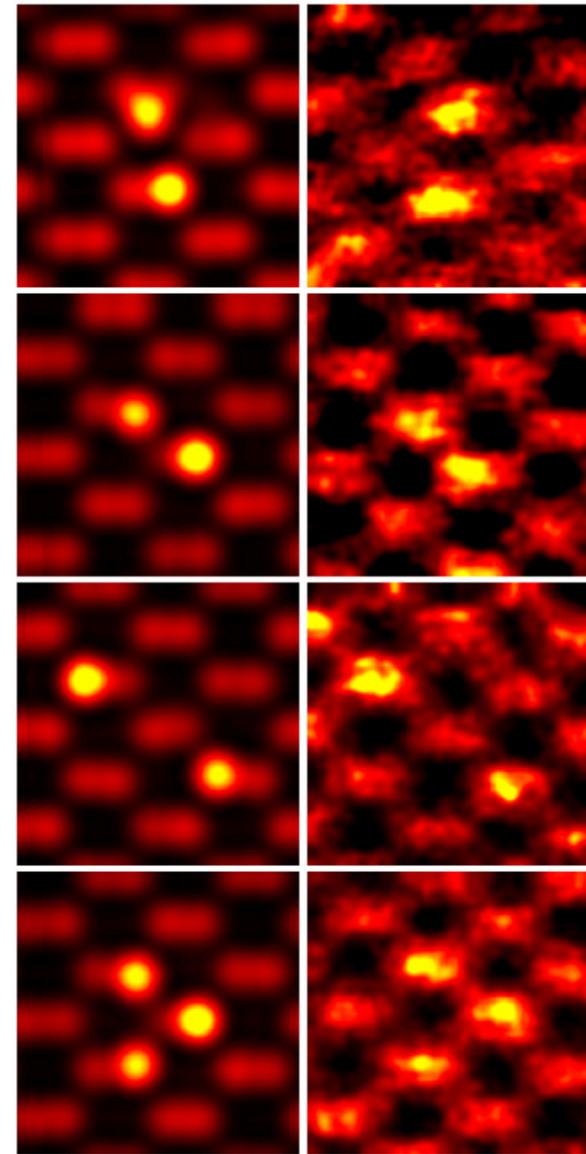
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Science and Engineering

THE UNIVERSITY  
*of*  
**WISCONSIN**  
MADISON

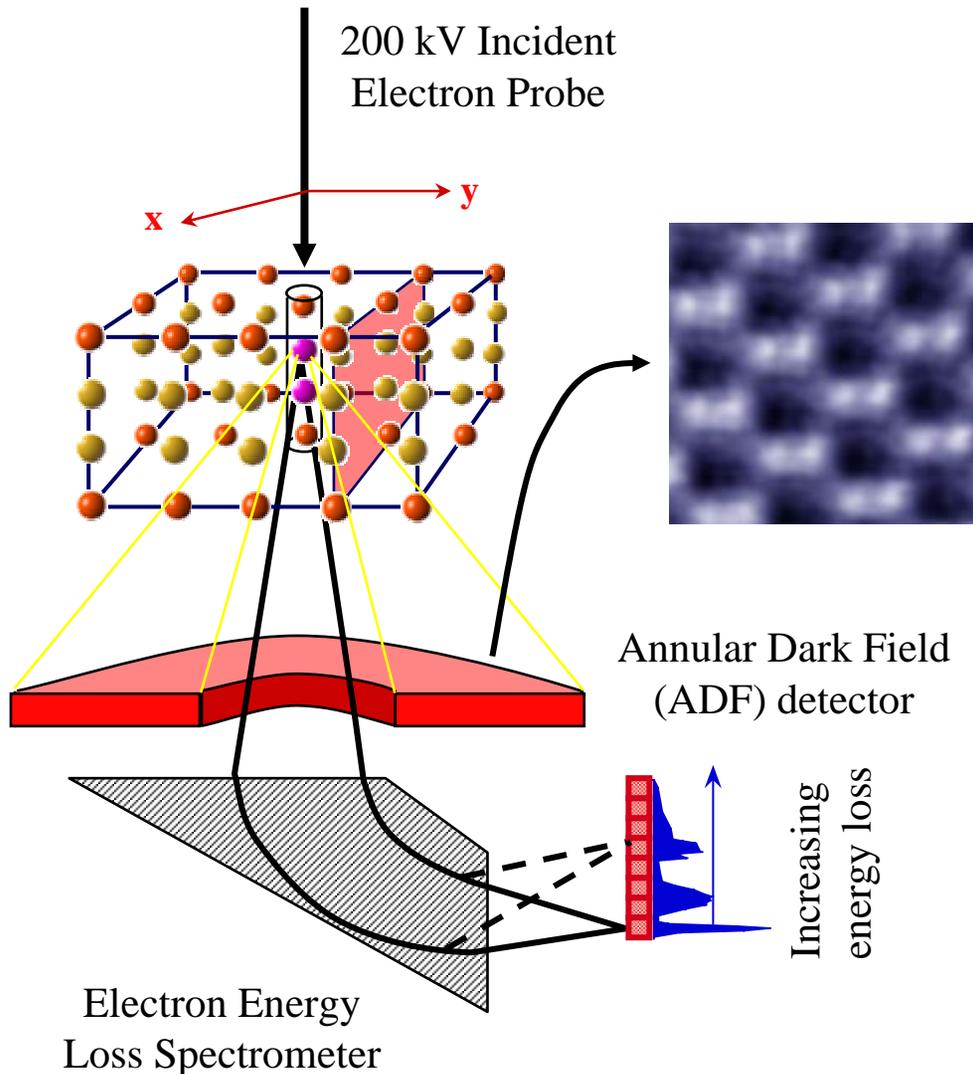


1 nm



- New technology and new capabilities: aberration correctors and monochromators
- New applications:
  - imaging and chemical analysis with single-atom sensitivity
  - imaging & spectroscopy of point defects
  - local valence-band spectroscopy
  - 3D, atomic scale imaging by tomography and optical sectioning
  - coherent scattering at nanometer resolution

# Scanning Transmission Electron Microscope



- atomic diameter probe raster scanned
- high-angle detector (no Bragg beams)
- low-angle, BF, and spectrometer also available
- views structure in projection along the beam direction

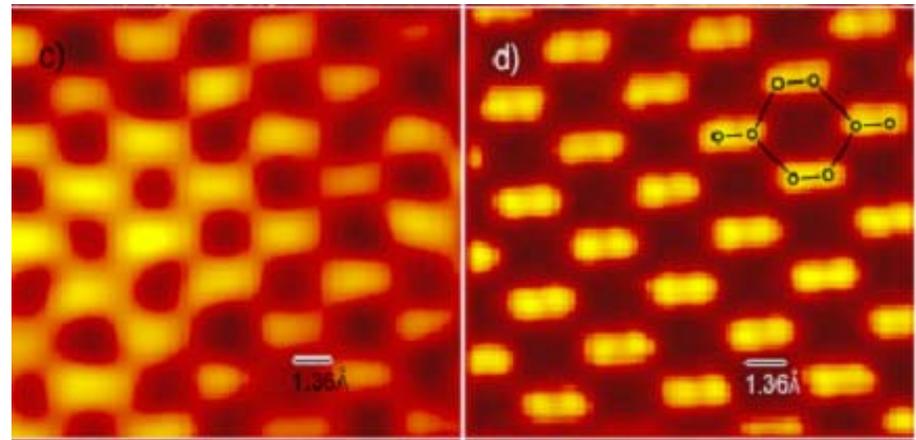
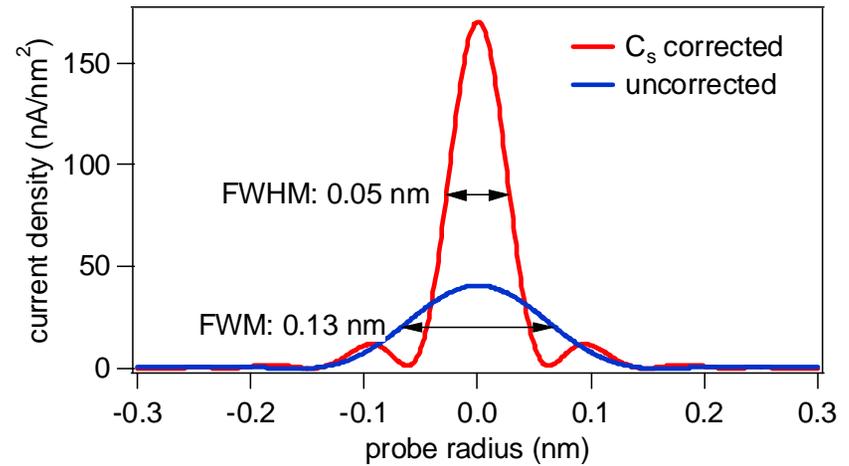
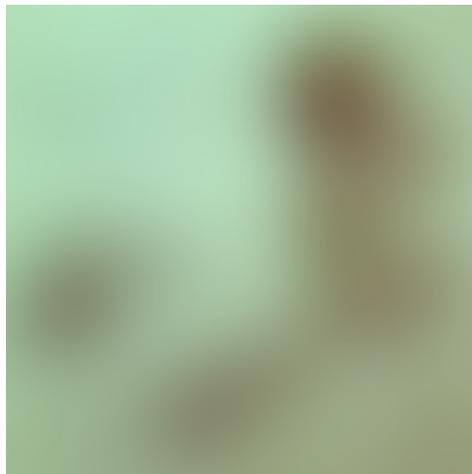
# Aberrations & Correcting Them

Current electron lenses have large 3<sup>rd</sup> order spherical aberration:

optical micrograph



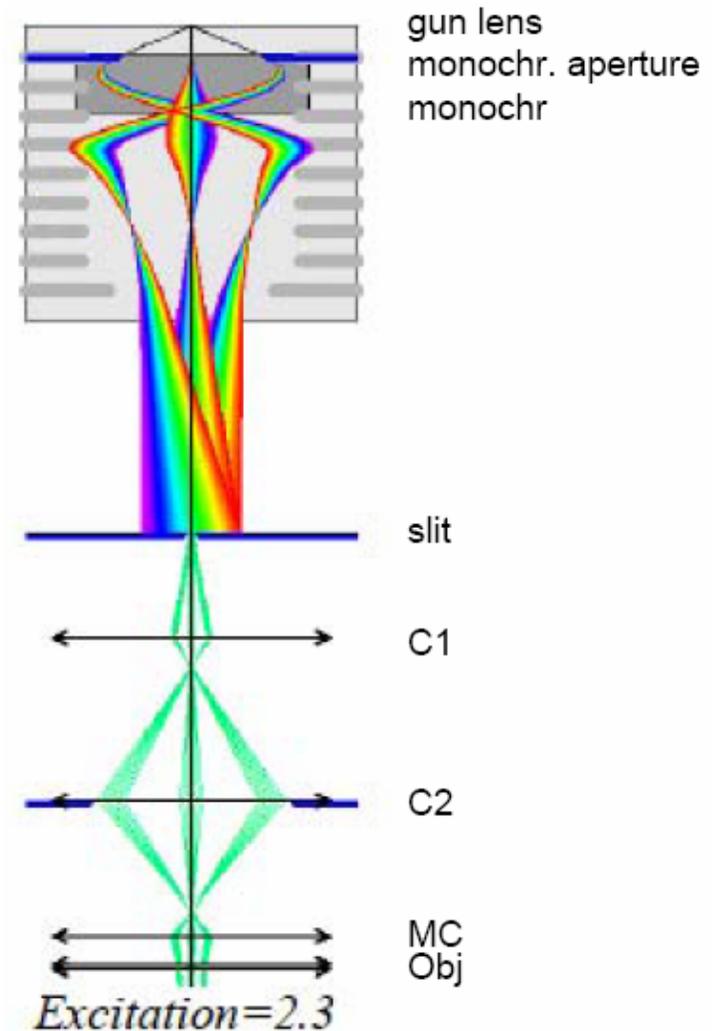
same micrograph  
with EM-like  $C_s$



P.E. Batson, N. Dellby, O.L. Krivanek,  
*Nature* **418**, 617 (2002).

# Monochromators

- TEM spectroscopic resolution limited by  $\Delta E$  of the beam.
- Beam  $\Delta E$  controlled by e-e scattering near the emitter.
- Cold field-emitter can achieve 0.3 eV; more common Schottky emitter 0.7 eV.
- Monochromator uses a slit in an energy dispersion plane to reduce  $\Delta E$ .
- 0.15 eV achievable on Schottky system, 0.06 eV on a cold FEG.



P.C. Tiemeijer, *Inst. Phys. Conf. Ser.* **161**, 191 (1999).

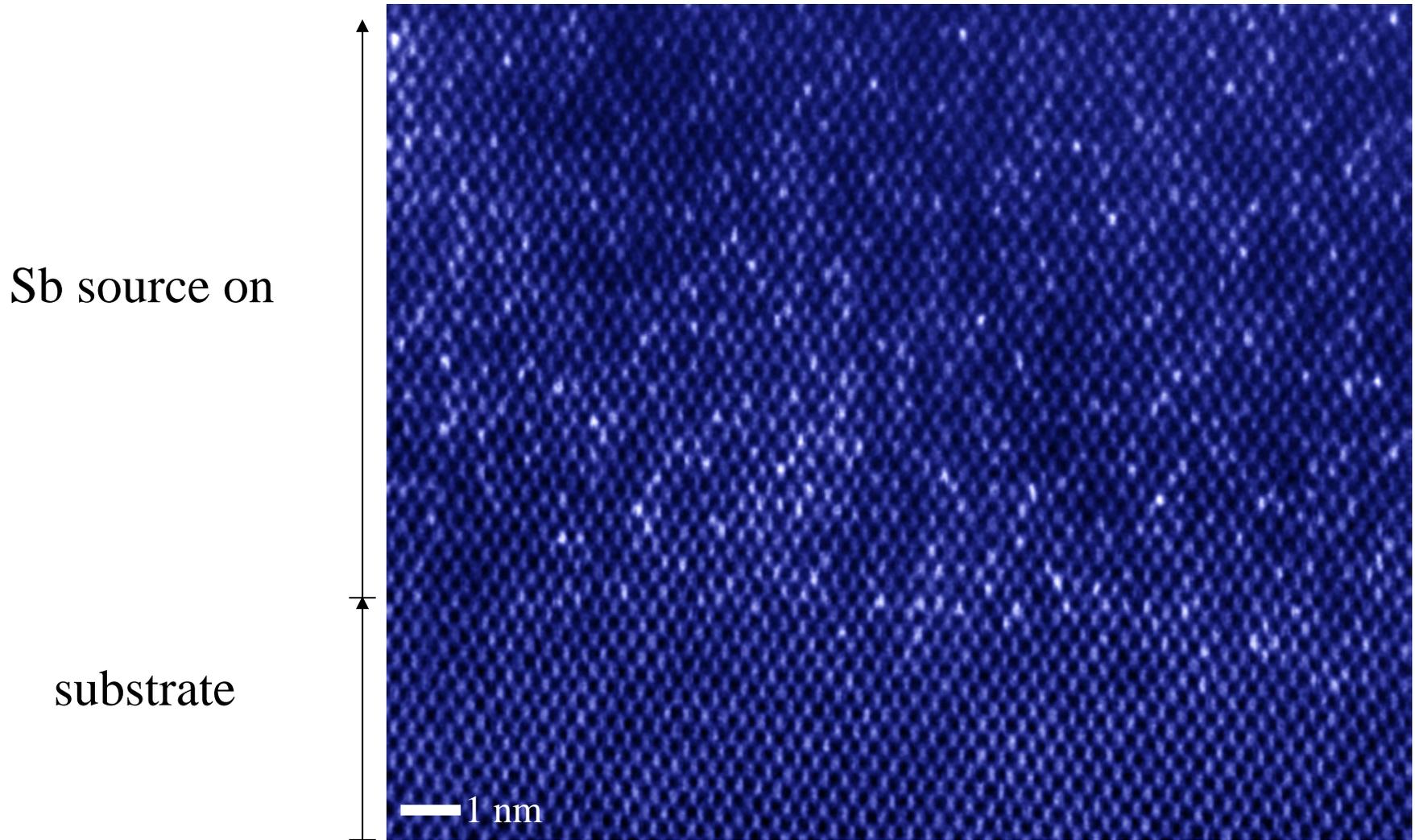
P.E. Batson, H. W. Mook, P. Kruit, *Inst. Phys. Conf. Ser.* **165**, 213 (2000)

# DoE TEAM Project



- TEAM = Transmission Electron Achromatic Microscope
- Build the world's first chromatic aberration corrected TEM.
- First instrument for NCEM @ LBL concentrated on highest achievable resolution.
- Subsequent instruments planned for other DoE e-beam centers @ UIUC, ORNL, and ANL.
- $C_s$  and  $C_c$  correction could allow 1 Å resolution with a sample area of ~1 cm, allowing much more flexibility in *in situ* experiments.

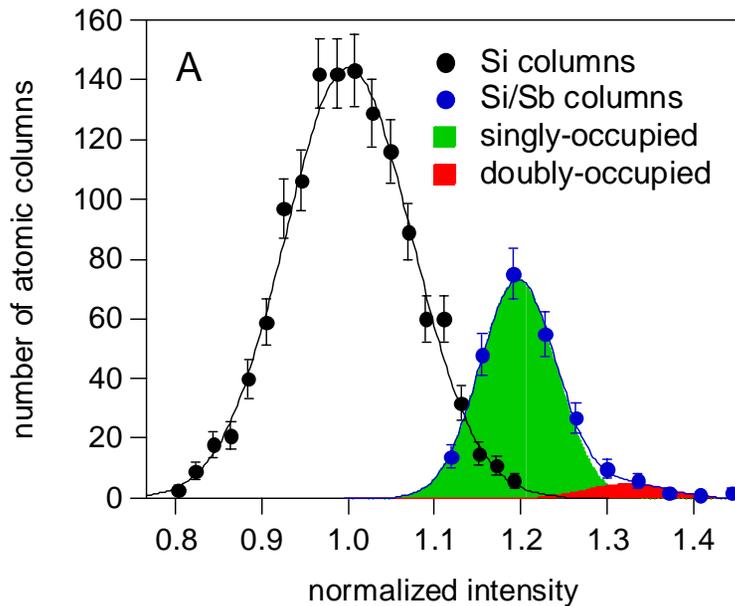
# Imaging Single Atoms



Most of the brightest dots are atomic columns with one Sb.

# Imaging Single Atoms

# of Sb atoms	Image A		Image B	
	measured	predicted	measured	predicted
0	1300 (50)	1300	2240 (70)	2234
1	230 (30)	223	470 (40)	468
2	15 (15)	17	20 (20)	45

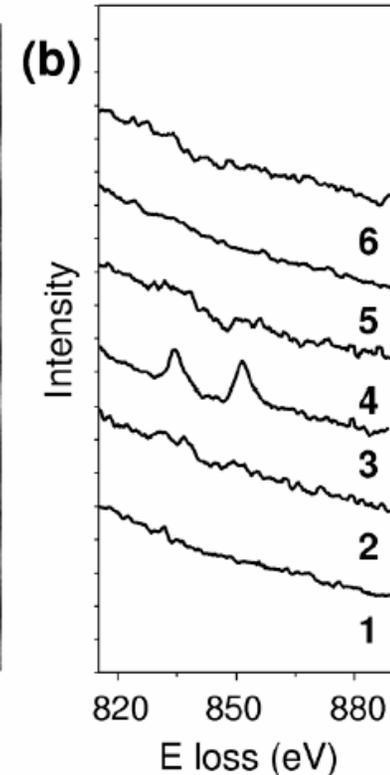
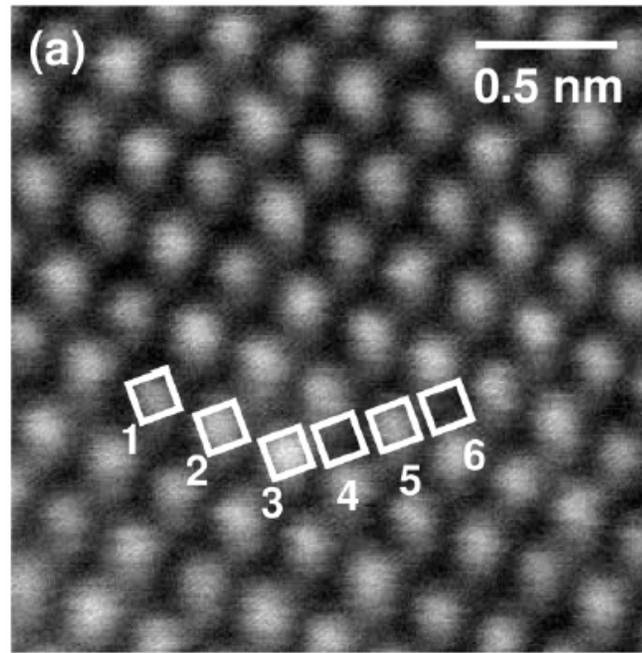


Results are consistent with random substitution of Sb on Si sites, measured with single-Sb sensitivity and ~100 % Sb detection efficiency.

First time single atoms have been imaged *in the bulk!*

# Chemistry of Single Atoms

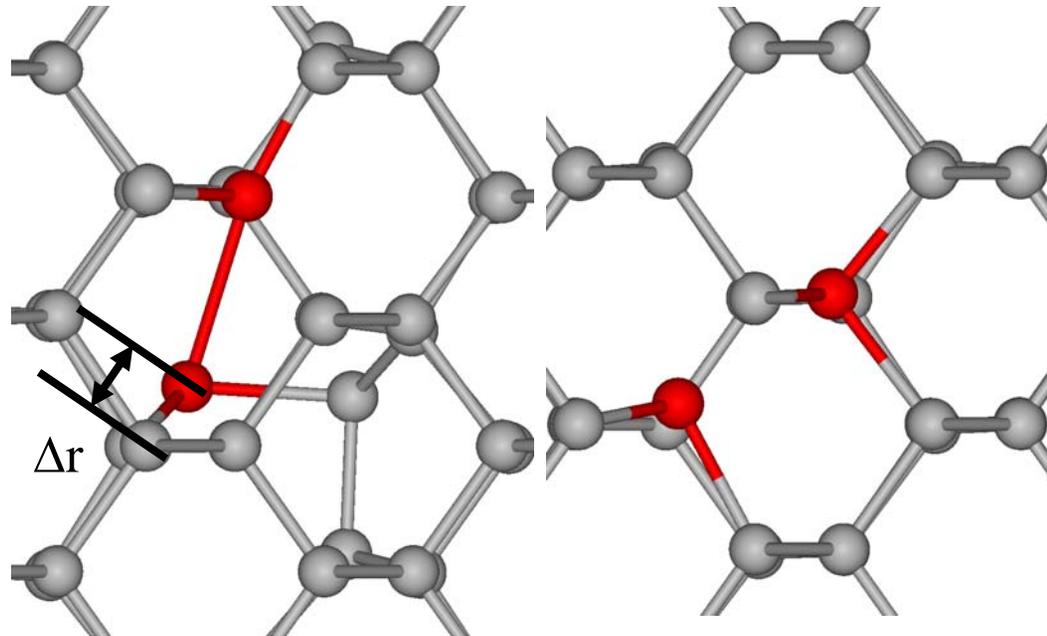
- Varela et al. Phys. Rev. Lett. **92**, 095502
- Aberration corrected STEM.
- Sample is lightly La doped  $\text{CaTiO}_3$
- Column 3 contains one La atom; spectrum 3 shows La  $M_{4,5}$  edge



- Column 2 is Ti, shows ~10 % intensity in EELS
- Column 4 is O, shows ~20 % intensity in EELS
- Points the way to single-atom electronic structure
  - valence of isolated impurities
  - natural or artificial charge ordering
  - trap states in semiconductors

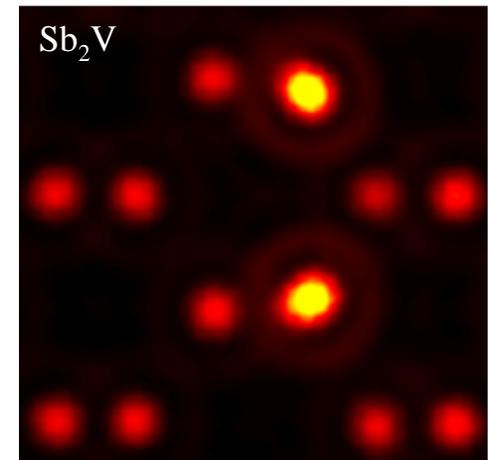
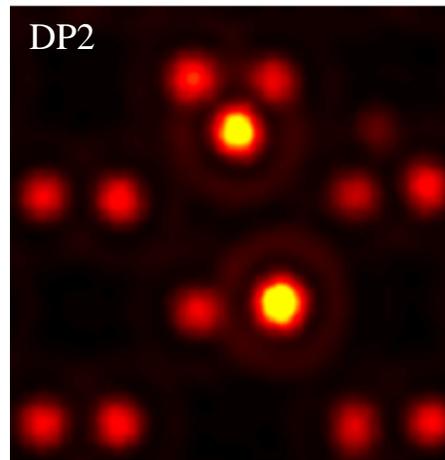
# Point Defect Complexes in Si

- At high concentration, donor impurities stop donating in Si.
- Various donor / point defect clusters proposed.
- Can't see the point defects directly, but with a aberration corrected STEM could see the off-site displacement of the heavy donor atoms.



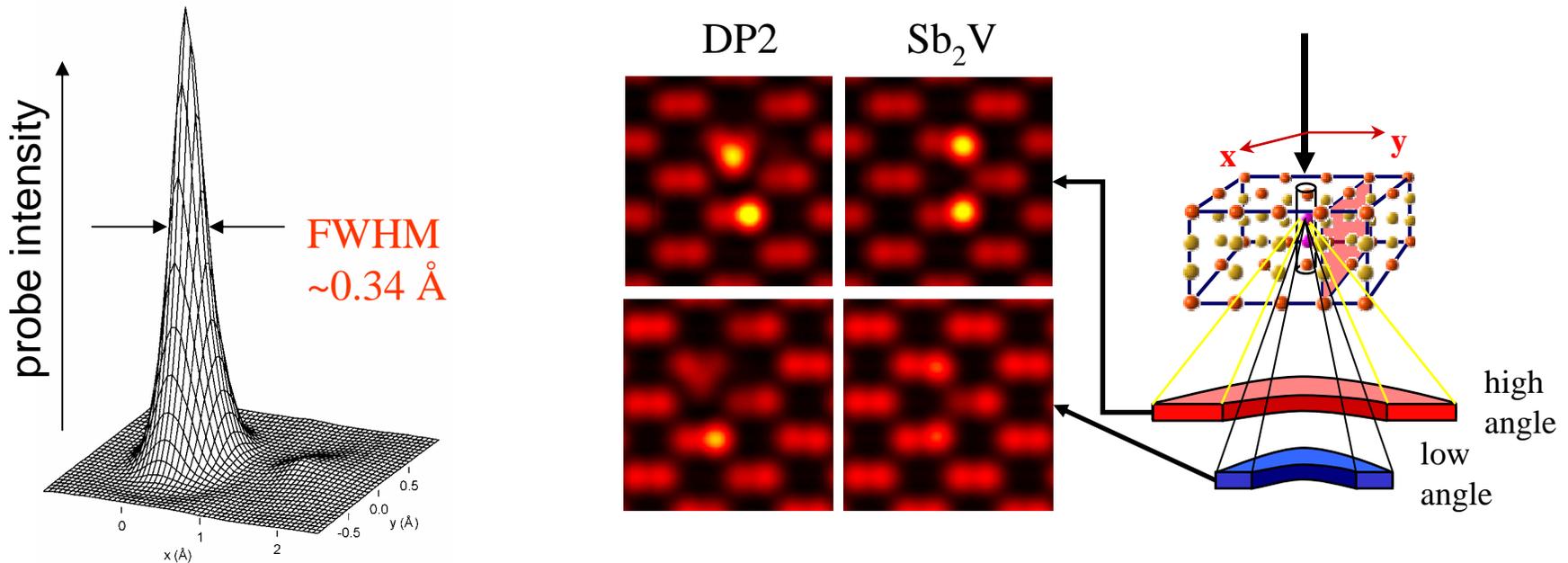
DP2

Sb<sub>2</sub>V



Simulated aberration-corrected STEM images

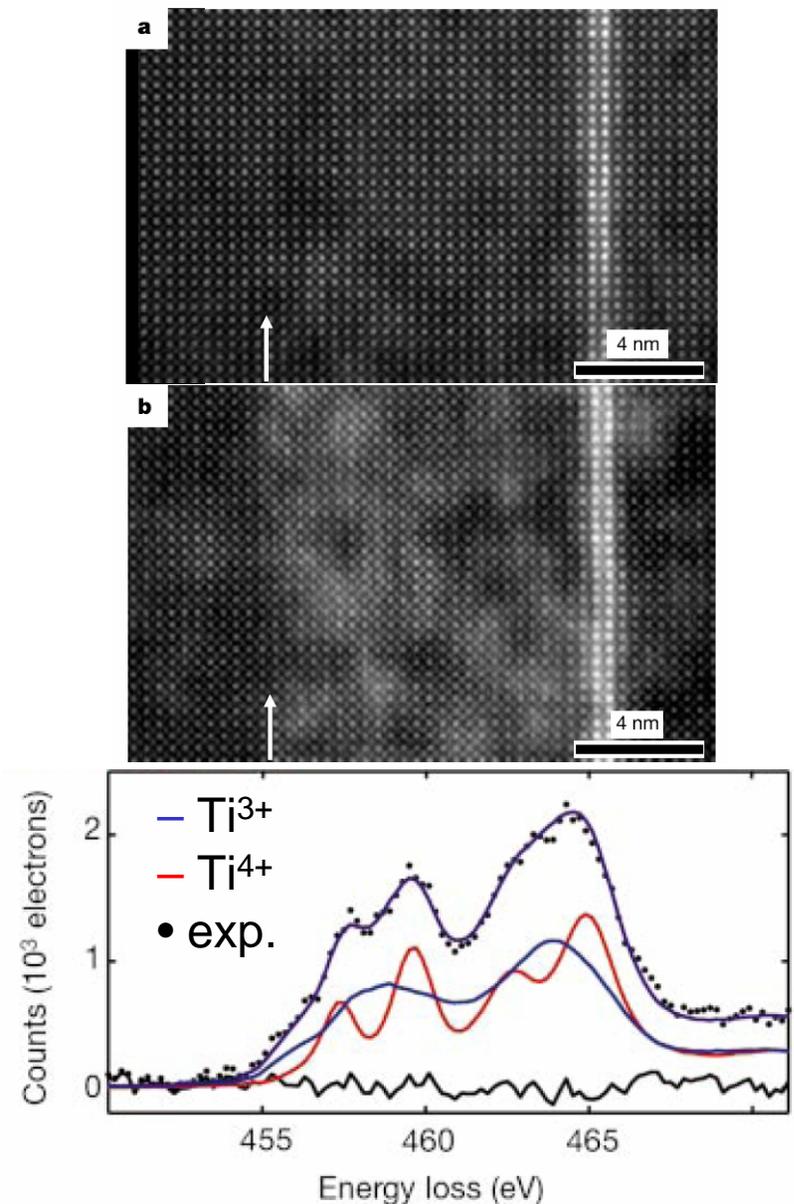
# Probe Channeling



- Probe  $e^-$  couple to  $1s$  state localized on the atomic column, acting like a local resolution boost for on-site impurities.
- Compare high-angle image emphasizing heavy atoms, to low-angle image emphasizing the lattice: Sb with large  $\Delta r$  will disappear.
- Result is that all Sb's have  $\Delta r < 0.3 \text{ \AA}$ , requiring a new model for the electrically deactivating defect.
- Voyles et al. PRL **91**, 125505 (2003).

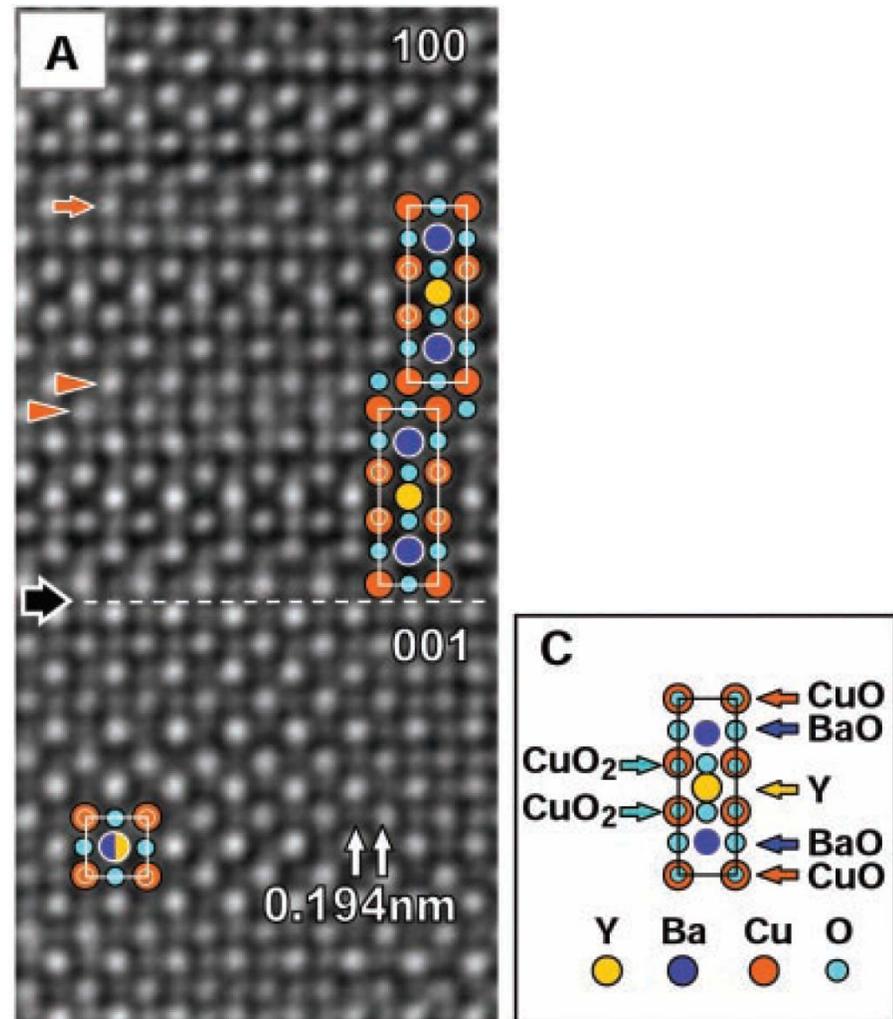
# O Vacancies in SrTiO<sub>3</sub>

- Muller et al., Nature **430**, 657 (2004).
- PLD homoepitaxial SrTiO<sub>3- $\delta$</sub> ;  $\delta$  varied by O partial pressure
- Vacancies appear in
  - O K-edge fine structure directly
  - Ti L<sub>2,3</sub> edge, which is sensitive to Ti valence
  - LAADF image via strain-induced dechanneling
- Detection limit 1-4 O<sub>V</sub>



# Imaging Anions Directly

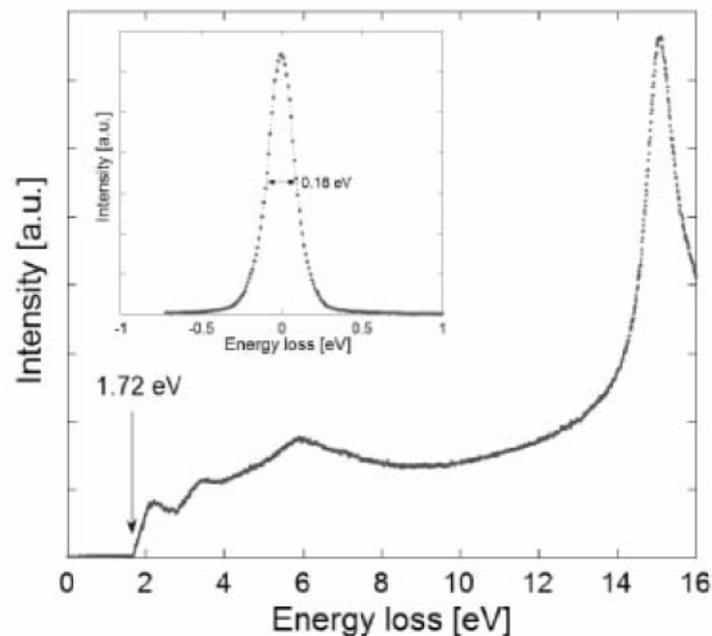
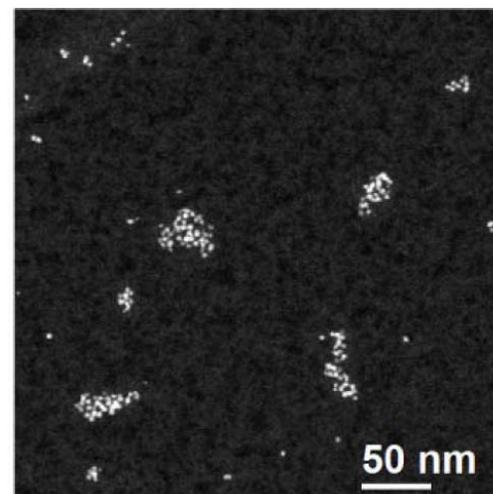
- Jia et al. *Science* **299**, 871 (2003).
- $C_s$  corrected TEM gives phase contrast, which is more sensitive to light atoms.
- O columns between Cu/O columns are resolved.
- Recent reports of detecting O vacancies by quantifying contrast, but have not been demonstrated on well-controlled samples.



90° tilt boundary in  $YBa_2Cu_3O_7$

# Interband Scattering by EELS

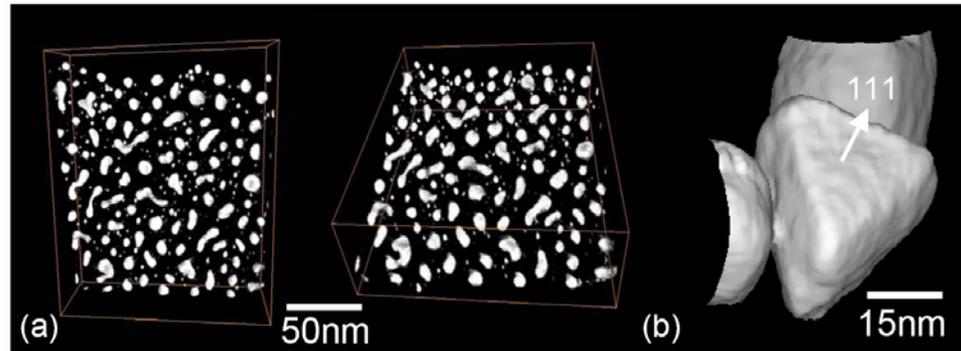
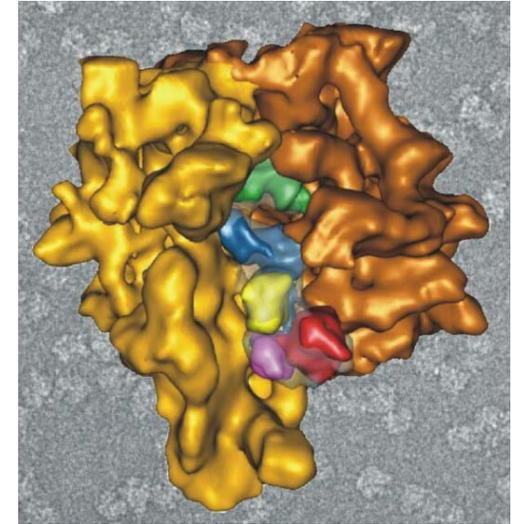
- High  $\Delta E$  from monochromator makes transition to conduction band visible in low-loss EELS.
- Measurements on single nanostructures:
  - Correlate bandgap, surface states, etc. with size, shape, atomic structure, and surface chemistry.
  - Measure anisotropy in single quantum dots.
  - R. Ermi, N. D. Browning, *Microsc. Microanal.* **10 Suppl. 2**, 842 (2004).
- Band bending at e.g. interfaces, edges of quantum wells.



# 3D: Tomography

- Requires monotonic intensity response with thickness.
- Commonplace in biology, where diffraction effects are minimal.
- Z-contrast STEM & energy-filtered TEM are enabling materials applications.
- 1 nm resolution achievable in 3D.
- EFTEM adds chemical information.

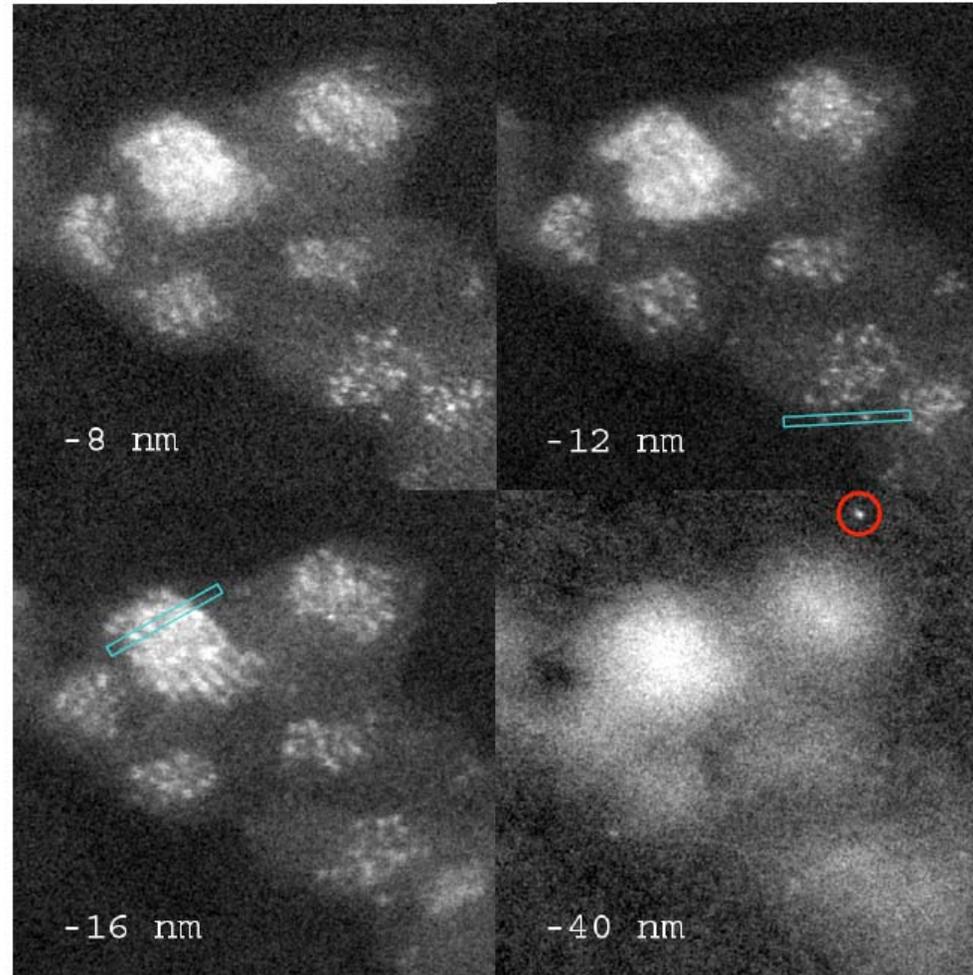
J. Harms et al.,  
Structure Fold Des  
7, 931-41. (1999)



P. A. Midgley et al., Microsc. Microanal. **10**  
**Suppl. 3**, 148 (2004).

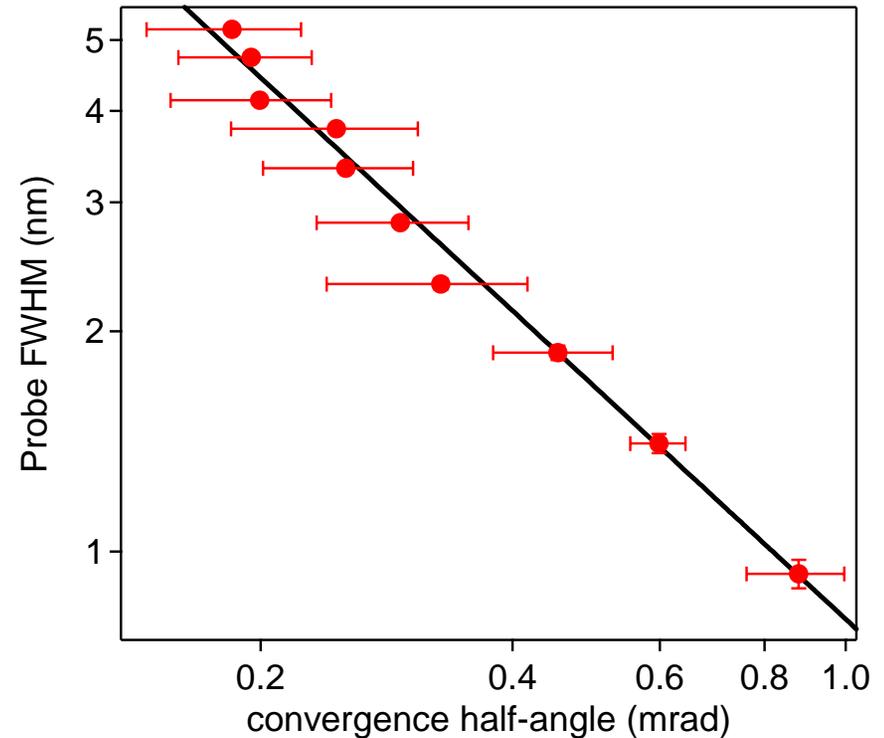
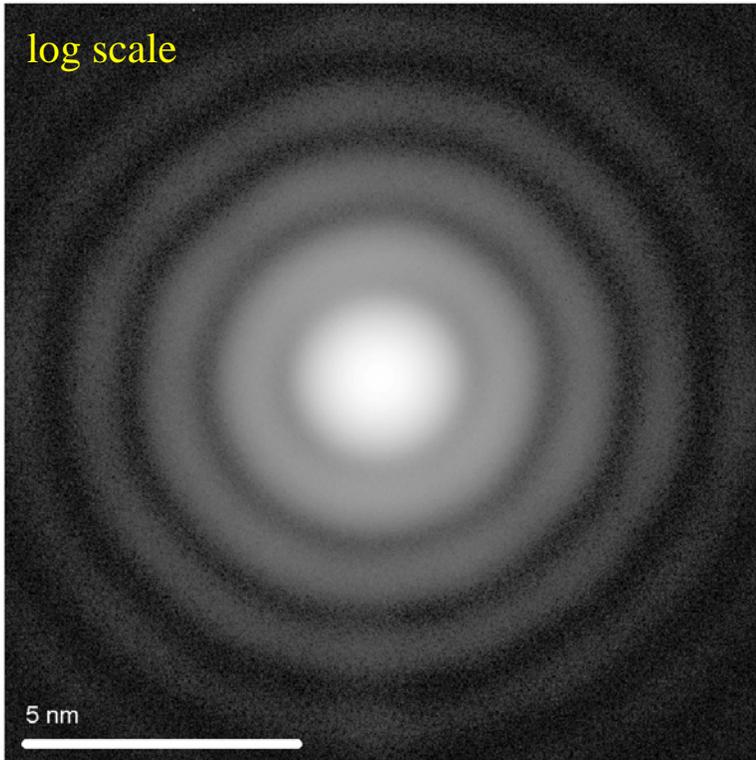
# 3D: Optical Sectioning

- Aberration correction means larger numerical apertures, limited depth of field.
- 3D imaging by a defocus series; optical sectioning.
- Current instruments vertical resolution of 6 nm
- Next generation 1.5 nm.



Through focus series of  $\text{Pt}_2\text{Ru}_4$  catalyst on a-C support. Pennycook et al. *Microsc. Microanal.* **10 Suppl. 3**, 1172 (2004).

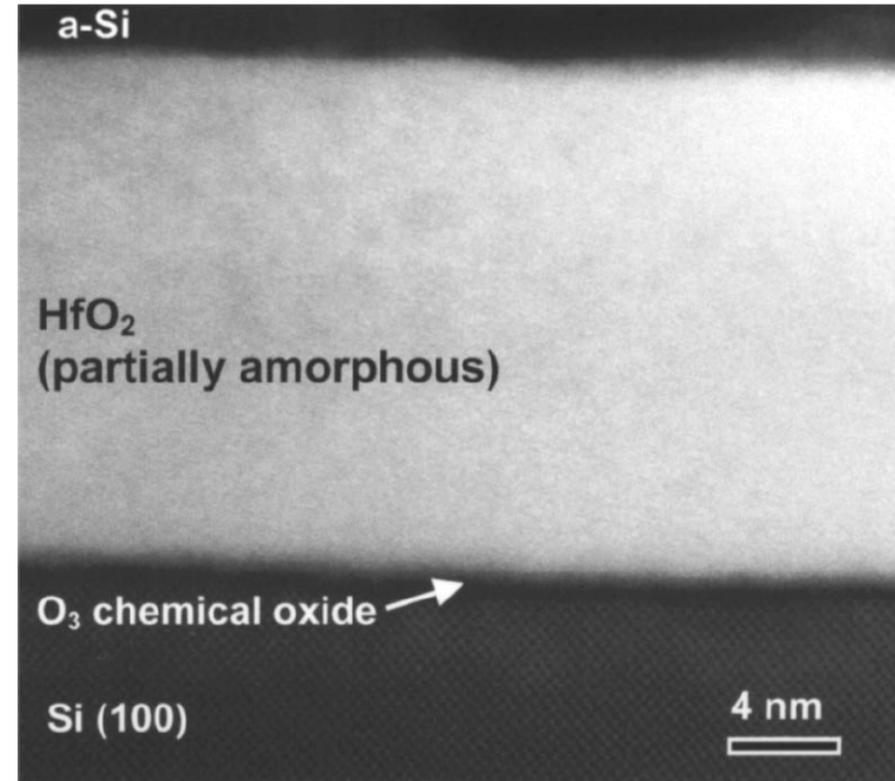
# Coherent Scattering



- High brightness field-emission sources can create coherent electron probes 0.5 – 5 nm in diameter.

# Amorphous Thin Films

- Pair distribution function is the basic structural diagnostic for amorphous materials.
- McBride [Ultramic. **76**, 115 (1999)] developed a method for measuring PDF from  $\sim 2$  nm volumes by deconvolution of convergent probe.
- Useful for thin films, interface layers, integrannular layers.

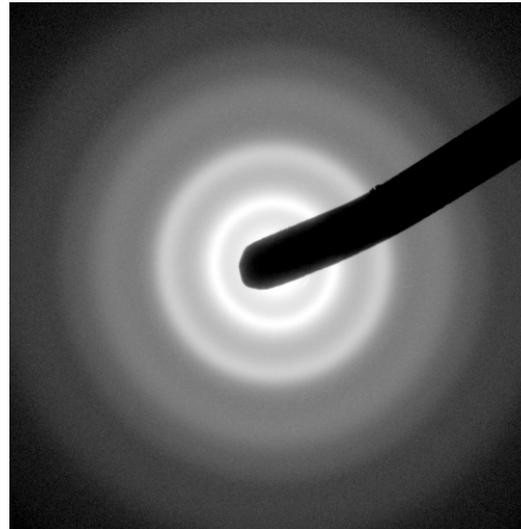


HfO<sub>2</sub> replacement gate dielectric with “amorphous” but heavily ordered structure (Ho et al. JAP **93**, 1477 (2003)).

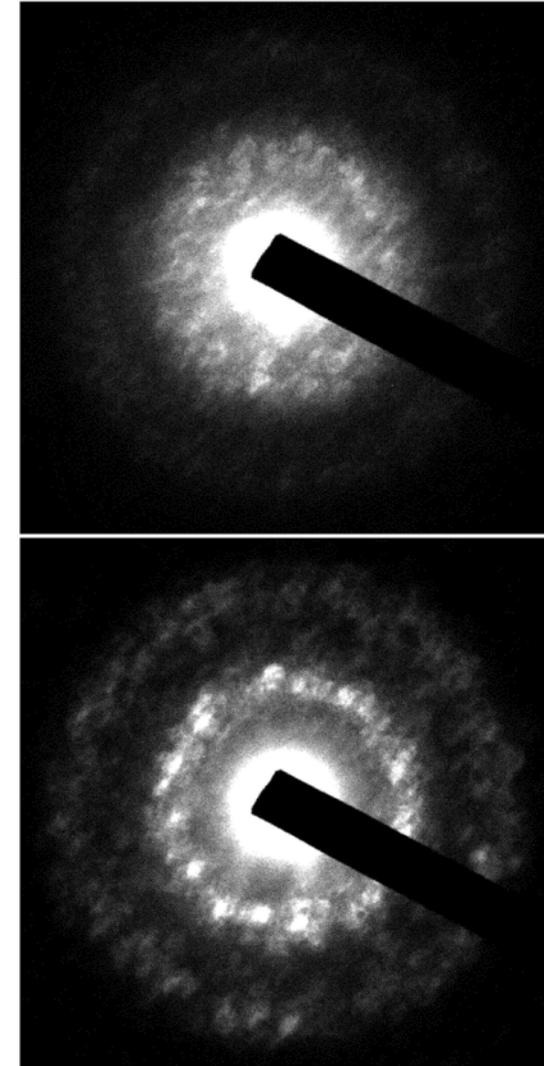
- Coherent probe size  $\cong$  structural correlation length.
- Magnitude of spatial fluctuations reveals heterogeneities in amorphous structure.
- Spatial analogy to photon correlation spectroscopy.

Different 1.5 nm areas:

Large area:  
average  $S(q)$



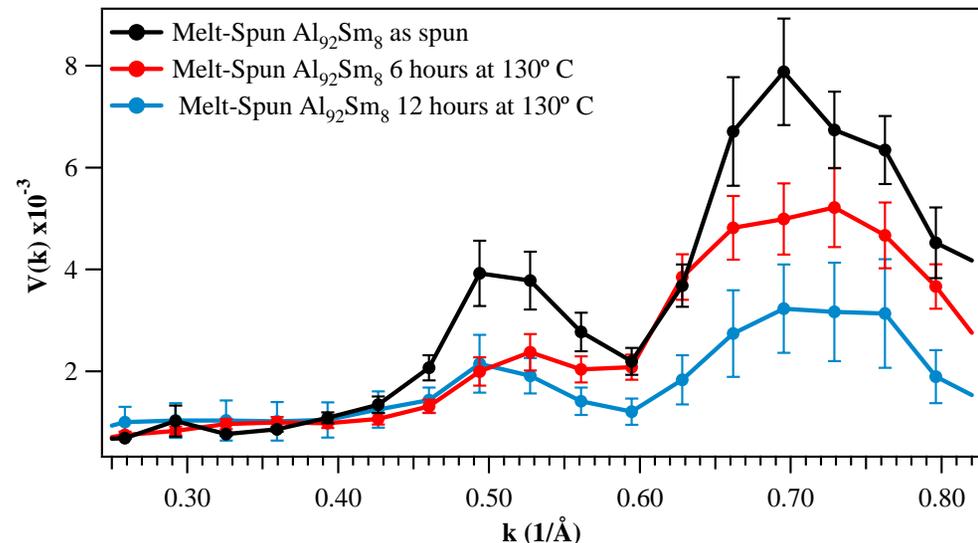
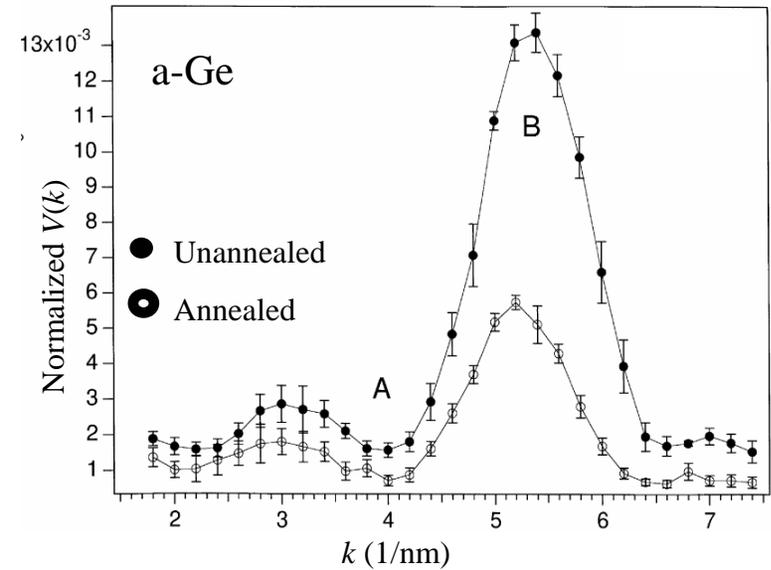
Voyles and Muller,  
*Ultramicroscopy* **93**,  
147 (2002).



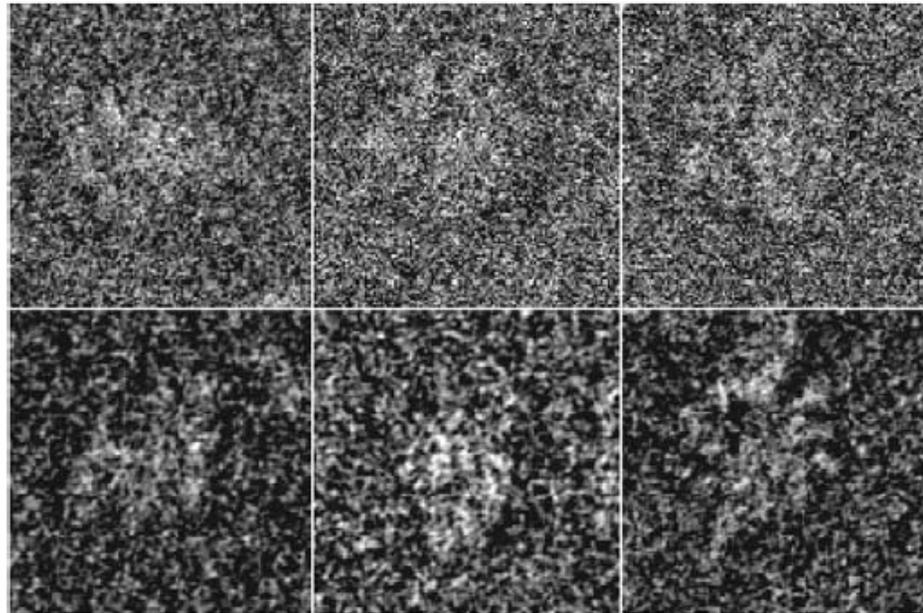
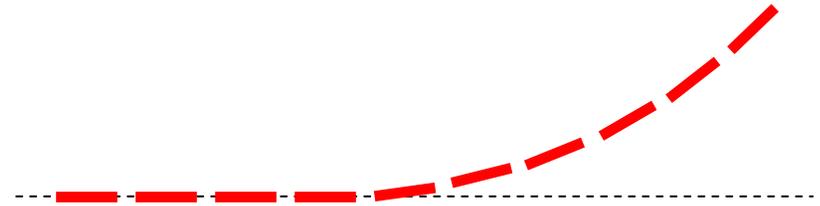
0.3  $\text{\AA}^{-1}$

# Fluctuation TEM

- Real amorphous semiconductors are not ideal continuous random networks (Gibson and Treacy PRL **78**, 1074 (1997)).
- Al-Sm metallic glass with high critical cooling rate contains structural order (Stratton et al. MRS Proc. **806** M9.4 (2003)).



- Persistence length in polymers from angular correlation along the chain.
- Phase separation in block copolymers
- Proteins
  - single particles in amorphous ice
  - set of many single-particle patterns contain more data than the average



70S ribosomes from *e. coli* imaged in different orientations (Gao et al. Ultramicroscopy **93**, 169 (2002))

# Perennial Limitations

- Samples must be thin
  - <10 nm for high-resolution measurements on typical crystals
- Samples must be in vacuum
  - Some environmental cell work in gas (Lee et al. Rev. Sci. Inst. **62**, 1438 (1991)) and now liquid environments (Williamson et al. Nature Materials **2**, 532 (2003)).
- **Radiation damage**
  - Several applications (e.g. spectroscopic identification of oxygen vacancies) limited by signal to noise, which is fundamentally limited by damage.
  - 3D imaging will require very high dose.

- Current or near-future EM offers:
  - Structural and chemical characterization at sub-Ångstrom resolution and single atom sensitivity.
  - Characterization of point defects under the right conditions.
  - $<0.2$  eV resolution spectroscopy of individual nanostructures, impurities, & defects.
  - 3D, nanometer resolution imaging
  - Nanoscale coherent scattering for characterization of amorphous materials